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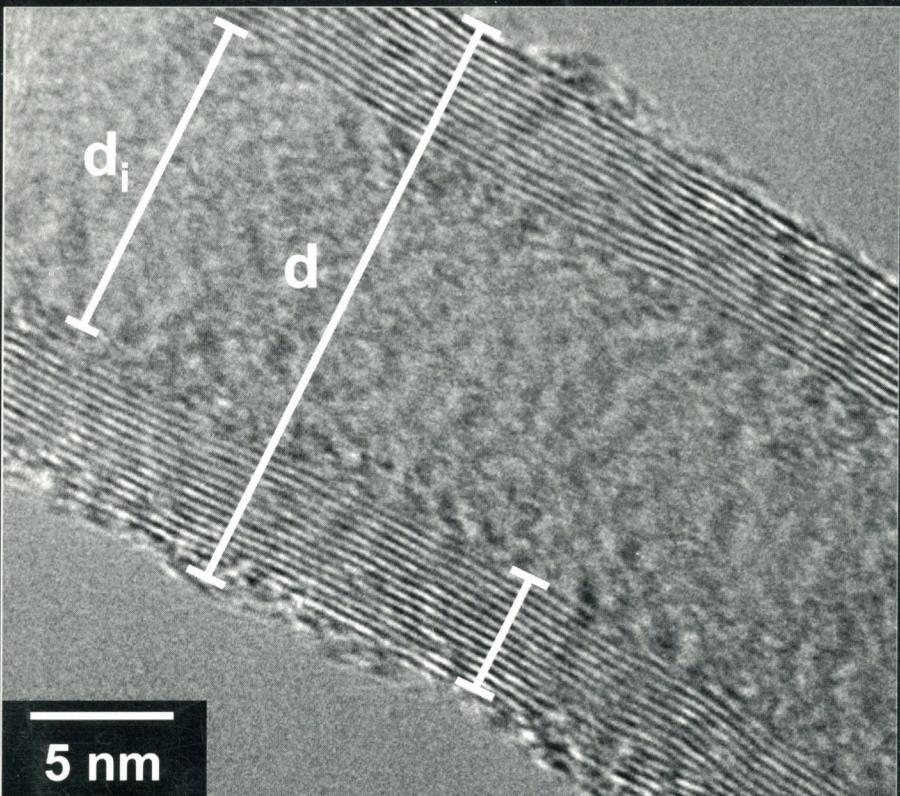
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Review article:

Micromechanical instruments for ferromagnetic measurements

J Moreland

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